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APPLICATION NO.	FI	LING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO
10/642,454	154 08/13/2003		Eugene P. Marsh	M122-2382	2187
21567	7590	09/29/2005		EXAMINER	
WELLS ST.	JOHN I	P.S.	VU, HUNG K		
601 W. FIRST AVENUE, SUITE 1300 SPOKANE, WA 99201				ART UNIT	PAPER NUMBER
				2811	

DATE MAILED: 09/29/2005

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)					
	10/642,454	MARSH, EUGENE P.					
Office Action Summary	Examiner	Art Unit					
	Hung Vu	2811					
The MAILING DATE of this communication appears on the cover sheet with the correspondence address Period for Reply							
A SHORTENED STATUTORY PERIOD FOR REPLY WHICHEVER IS LONGER, FROM THE MAILING DA  - Extensions of time may be available under the provisions of 37 CFR 1.13 after SIX (6) MONTHS from the mailing date of this communication.  If NO period for reply is specified above, the maximum statutory period w  - Failure to reply within the set or extended period for reply will, by statute, Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	ATE OF THIS COMMUNICATION 36(a). In no event, however, may a reply be tim rill apply and will expire SIX (6) MONTHS from cause the application to become ABANDONEI	I.  lely filed  the mailing date of this communication.  D (35 U.S.C. § 133).					
Status							
Responsive to communication(s) filed on	action is non-final. nce except for formal matters, pro						
Disposition of Claims							
4) Claim(s) 29-37,40-46 and 48 is/are pending in the day of the above claim(s) is/are withdraw 5) Claim(s) is/are allowed.  6) Claim(s) 29-37,40-46 and 48 is/are rejected.  7) Claim(s) is/are objected to.  8) Claim(s) are subject to restriction and/or	vn from consideration.						
Application Papers .							
9) The specification is objected to by the Examiner.							
10) The drawing(s) filed on is/are: a) accepted or b) objected to by the Examiner.							
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).							
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).  11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.							
Priority under 35 U.S.C. § 119							
12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).  a) All b) Some * c) None of:  1. Certified copies of the priority documents have been received.  2. Certified copies of the priority documents have been received in Application No.  3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).  * See the attached detailed Office action for a list of the certified copies not received.							
Attachment(s)  1) Notice of References Cited (PTO-892)  2) Notice of Draftsperson's Patent Drawing Review (PTO-948)  3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) Paper No(s)/Mail Date	4) Interview Summary Paper No(s)/Mail Da 5) Notice of Informal P 6) Other:						

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#### **DETAILED ACTION**

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Per telephone communication on 08/26/05 between the Applicant's representative and the examiner regarding the status of missing claims 44 – 46 and 48 in the Office Action Paper No. 032005, the rejections are accordingly withdrawn. In view of a further consideration and/or search, however, a new rejection is set forth further below. This action is not made final.

### Double Patenting

2. The nonstatutory double patenting rejection is based on a judicially created doctrine grounded in public policy (a policy reflected in the statute) so as to prevent the unjustified or improper timewise extension of the "right to exclude" granted by a patent and to prevent possible harassment by multiple assignees. See *In re Goodman*, 11 F.3d 1046, 29 USPQ2d 2010 (Fed. Cir. 1993); *In re Longi*, 759 F.2d 887, 225 USPQ 645 (Fed. Cir. 1985); *In re Van Ornum*, 686 F.2d 937, 214 USPQ 761 (CCPA 1982); *In re Vogel*, 422 F.2d 438, 164 USPQ 619 (CCPA 1970);and, *In re Thorington*, 418 F.2d 528, 163 USPQ 644 (CCPA 1969).

A timely filed terminal disclaimer in compliance with 37 CFR 1.321(c) may be used to overcome an actual or provisional rejection based on a nonstatutory double patenting ground provided the conflicting application or patent is shown to be commonly owned with this application. See 37 CFR 1.130(b).

Effective January 1, 1994, a registered attorney or agent of record may sign a terminal disclaimer. A terminal disclaimer signed by the assignee must fully comply with 37 CFR 3.73(b).

Claims 29, 33-37, 40-46 and 48 are rejected under the judicially created doctrine of obviousness-type double patenting as being unpatentable over claims 5-10, 12-16 and 19 of U.S. Patent No. 5,990,559. Although the conflicting claims are not identical, they are not patentably distinct from each other because claims 29, 33-37, 40-46 and 48 are generic to claims 5-10, 12-16 and 19 of U.S. Patent No. 5,990,559. The claimed invention (claims 29, 33-37, 40-46 and 48) of the present application is a mere broader version of the claimed invention (claims 5-10, 12-16).

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and 19) of the above identified U.S. Patent with similar intended scope, thus allowing unjustified or improper timewise extension of the "right to exclude" granted by a U.S. Patent No. 5,990,559.

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## Claim Rejections - 35 USC § 102

3. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(e) the invention was described in (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent or (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filed in the United States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.

Claims 29, 33 and 37 are rejected under 35 U.S.C. 102(e) as being anticipated by Nakamura (PN 6,232,629, of record).

Nakamura discloses a capacitor comprising,

a semiconductive substrate (102);

a roughened platinum layer (112) over the substrate, the roughened platinum layer comprising columnar platinum pedestals terminating in dome-shaped tops.

Regarding claim 33, Nakamura discloses the roughened platinum layer has a continuous surface characterized by columnar platinum pedestals, wherein the column platinum pedestals have heights greater than or equal to about one-third of a total thickness of the roughened platinum. Note Figures 1 - 35 (especially Figures 2, 3A, 7 - 10D, and 24 - 32) of Nakamura.

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Regarding claim 37, Nakamura discloses the circuit further comprisig an adhesion layer between

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the platinum layer and the substrate, the adhesion layer comprising at least one of IrO2, RuO2,

RhO<sub>2</sub>, or OsO<sub>2</sub>.

4. Claims 40-41, 44 and 48 are rejected under 35 U.S.C. 102(e) as being anticipated by

Inaba et al. (H09-239891, of record).

Inaba et al. discloses, as shown in Figures (a) and (b), a capacitor comprising:

a first capacitor electrode (3) (see Sections [0025] and [0026]);

a second capacitor electrode (see Section [0028]);

a dielectric layer (see Section [0027]) between the first and second capacitor electrodes;

wherein at least one of the first and second capacitor electrodes comprise roughened

platinum, the roughened platinum having a thickness of from about 400Å to about 1000Å and

comprising platinum pedestals that are at least about 300Å tall and terminate in dome-shaped

tops (see Section [0015]).

Regarding claim 41, Inaba et al. discloses the roughened platinum layer comprises hemispherical

grain platinum.

Regarding claim 44, Inaba et al. discloses, as shown in Figures (a) and (b), a capacitor

comprising:

a first capacitor electrode (3) (see Sections [0025] and [0026]);

a second capacitor electrode (see Section [0028]);

a dielectric layer (see Section [0027]) between the first and second capacitor electrodes; wherein at least one of the first and second capacitor electrodes comprise roughened platinum, the roughened platinum having a continuous surface characterized by columnar platinum pedestals having heights greater than or equal to about one-third of a total thickness of the platinum layer;

the platinum pedestals terminating in dome-shaped tops (see Section [0015]).

Regarding claim 48, Inaba et al. discloses the platinum pedestals terminate in hemispherical tops.

## Claim Rejections - 35 USC § 103

- 5. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
  - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 30-32 and 34-36 are rejected under 35 U.S.C. 103(a) as being unpatentable over Nakamura (PN 6,232,629, of record).

Regarding claims 30 and 34-36, Nakamura discloses the claimed invention including the circuit as explained in the rejection above. Nakamura further disclose the roughened platinum layer is continuous over an area of the substrate. Nakamura does not disclose the value of the area of the substrate and the thickness of the pedestals. Although Nakamura does not teach the value of the area and the thickness of the pedestals, as that claimed by Applicants, however, it would have been obvious to one having ordinary skill in the art at the time the invention was made to form

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the substrate having the desired area and the platinum pedestals having a desired thickness, since it has been held that discovering an optimum value of a result effective variable involves only routine skill in the art. In re Boesch, 617 F.2d 272, 205 USPQ 215 (CCPA 1980).

Regarding claim 31, Nakamura discloses the platinum layer comprises hemispherical grain platinum.

Regarding claim 32, Nakamura discloses the claimed invention including the circuit as explained in the rejection above. Nakamura does not disclose the area of the substrate comprises a square. However, it would have been obvious to one of ordinary skill in the art to form the substrate having the shape of a square since it is well settled that, the change in shape of the substrate was a matter of design choice which a person of ordinary skill in the art would have found obvious absent persuasive evidence that the particular configuration of the substrate was significant. *In re Dailey*, 357 F.2d 669, 149 USPTO 47 (CCPA 1996).

6. Claims 42-43 and 45-46 are rejected under 35 U.S.C. 103(a) as being unpatentable over Inaba et al. (H09-239891, of record).

Regarding claim 42, Inaba et al. discloses the claimed invention including the circuit as explained in the rejection above. Inaba et al. further disclose the roughened platinum layer is continuous over an area of the substrate. Inaba et al. does not disclose the value of the area of the substrate. Although Nakamura does not teach the value of the area, as that claimed by Applicants, however, it would have been obvious to one having ordinary skill in the art at the

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time the invention was made to form the substrate having the desired area, since it has been held that discovering an optimum value of a result effective variable involves only routine skill in the art. In re Boesch, 617 F.2d 272, 205 USPQ 215 (CCPA 1980).

Regarding claim 43, Inaba et al. discloses the claimed invention including the circuit as explained in the rejection above. Inaba et al. does not disclose the area of the substrate comprises a square. However, it would have been obvious to one of ordinary skill in the art to form the substrate having the shape of a square since it is well settled that, the change in shape of the substrate was a matter of design choice which a person of ordinary skill in the art would have found obvious absent persuasive evidence that the particular configuration of the substrate was significant. *In re Dailey*, 357 F.2d 669, 149 USPTO 47 (CCPA 1996).

Regarding claim 45, Inaba et al. discloses the claimed invention including the circuit as explained in the rejection above. Inaba et al. further disclose at least one of the first and second capacitor electrodes comprises the roughened platinum layer. Inaba et al. does not disclose both capacitor electrodes comprise platinum. However, it would have been obvious to one of ordinary skill in the art at the time the invention was made to form the circuit of Inaba et al. having both capacitor electrodes comprise platinum as that claimed by Applicant, since it has been held to be within the general skill of a worker in the art to select a known material on the basis of its suitability for the intended use as a matter of obvious design choice. *In re Leshin*, 125 USPQ 416.

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Regarding claim 46, it is inherent that the second capacitor electrode of Inaba et al. forms on the

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roughened dielectric layer will have the roughened surface.

Conclusion

7. Any inquiry concerning this communication or earlier communications from the

examiner should be directed to Hung K. Vu whose telephone number is (571) 272-1666. The

examiner can normally be reached on Tuesday-Friday 6:00-4:30, Eastern Time.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's acting

supervisor, Steven Loke can be reached on (571) 272-1657. The Central Fax Number for the

organization where this application or proceeding is assigned is (571) 273-8300.

Any inquiry of a general nature or relating to the status of this application or proceeding

should be directed to the receptionist whose telephone number is (703) 308-0956.

Vu

August 30, 2005

Hung Vu

Primary Examiner